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# NANO LETTERS



## Modulation Doping of GaAs/AlGaAs Core–Shell Nanowires With Effective Defect Passivation and High Electron Mobility

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**Supporting Information** 

**ABSTRACT:** Reliable doping is required to realize many devices based on semiconductor nanowires. Group III–V nanowires show great promise as elements of high-speed optoelectronic devices, but for such applications it is important that the electron mobility is not compromised by the inclusion of dopants. Here we show that GaAs nanowires can be n-type doped with negligible loss of electron mobility. Molecular beam epitaxy was used to fabricate modulation-doped GaAs nanowires with  $Al_{0.33}Ga_{0.67}As$  shells that contained a layer of Si dopants. We identify the presence of the doped layer from a high-angle annular dark field scanning electron microscopy cross-section image. The doping density, carrier mobility, and charge



carrier lifetimes of these n-type nanowires and nominally undoped reference samples were determined using the noncontact method of optical pump terahertz probe spectroscopy. An n-type extrinsic carrier concentration of  $1.10 \pm 0.06 \times 10^{16}$  cm<sup>-3</sup> was extracted, demonstrating the effectiveness of modulation doping in GaAs nanowires. The room-temperature electron mobility was also found to be high at  $2200 \pm 300$  cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and importantly minimal degradation was observed compared with undoped reference nanowires at similar electron densities. In addition, modulation doping significantly enhanced the room-temperature photoconductivity and photoluminescence lifetimes to  $3.9 \pm 0.3$  and  $2.4 \pm 0.1$  ns respectively, revealing that modulation doping can passivate interfacial trap states.

KEYWORDS: GaAs, modulation doping, terahertz spectroscopy, photoconductivity, surface plasmon, mobility, photoluminescence

**S** emiconductor nanowires are attractive in the field of nanotechnology owing to their potential as building blocks for compact ultrafast electronic and optoelectronic devices.<sup>1</sup> They have already been shown to have a variety of practical applications, from photovoltaics<sup>2-4</sup> to nanoscale lasers<sup>5,6</sup> and light-emitting diodes.<sup>7,8</sup> In order to create functional electronic devices, it is necessary to be able to control the charge carrier concentration in these nanowires. One way of implementing this is through deliberate incorporation of dopants to control the nanowire conductivity.

Doping in semiconductor nanowires was first investigated by the Hiruma group with the demonstration of GaAs p-njunctions.<sup>9</sup> Since then, both bulk n-type and p-type doping have been fabricated in GaAs nanowires.<sup>10–14</sup> Bulk doping has been shown to yield a high doping concentration but at the expense of a reduction in electron mobility resulting from impurity scattering.<sup>15,16</sup> Thus, other doping mechanisms that allow for both a high extrinsic carrier concentration and carrier mobility are of great interest. Modulation doping is one such mechanism, as it has been shown to avoid a decrease in electron mobility at low temperatures for planar semiconductor heterostructures,<sup>17</sup> as ionized impurities are separated from free charge carriers. By applying modulation doping to semiconductor nanowires, it is predicted that their carrier mobility and transport properties could be improved.<sup>18</sup> Thus, the growth and characterization of such nanostructures has become an important area of research.<sup>19</sup>

In practice, doping of III–V nanowires has been shown to be more difficult than doping of conventional layered devices with modulation doping, in particular, being a challenging area of research. Dopant incorporation can differ for lateral and axial growth, leading to inhomogeneous doping, compensation, or ineffective doping.<sup>20–23</sup> However, in the past few years, advances in the growth of modulation-doped nanowires have been made.<sup>18,24–26</sup> Several types of III–V semiconductor

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heterostructures have been realized, which provide real potential for obtaining high carrier mobilities. For example, a thin InAs nanowire was fabricated that was capped with a 6 nm thick InP shell containing a delta-doping layer at a 3 nm distance from the nanowire core. Even though InAs and InP are lattice mismatched, the structure did not contain any dislocations. The shell provided electrons at the InAs interface and at the same time it separated them from the nanowire surface, which also contained charged species. Electrical transport measurements demonstrated an increase of mobility from 2000 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> up to 15 600 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> at 100 K for this nanostructure.<sup>27</sup>

Since then, other groups have attempted modulation-doped nanowire-based structures for the GaAs/AlGaAs system.<sup>24-26</sup> The optical and electronic properties of GaAs nanowires have been extensively studied  $^{28-32}$  and growth optimized to give the best electronic performance, making them prime candidates for modulation doping. GaAs/AlGaAs systems also allow the positioning of the delta doping layer to be further away from the conducting channel, which should further increase the carrier mobility. Recently, magneto-conductance measurements on single GaAs nanowires with a modulation-doped structure were published.<sup>26,33</sup> Universal conductance fluctuations indicated a phase coherence length of up to 250 nm in the core of the structure, which should increase as the mobility is improved. For such nanowires, it is important that carrier concentrations and mobilities are accurately evaluated so that the structure can be tailored for optimized electronic performance. This proves difficult using conventional Hall techniques, owing to the quasi-one-dimensional geometry of nanowires and difficulties in fabricating the lateral contacts needed for such measurements.<sup>34</sup> Thus, other noncontact methods, such as Raman spectroscopy, are currently being investigated for accurate analysis of the carrier density in nanowires,<sup>35</sup> yet the evaluation of carrier concentrations and mobilities remains technically difficult.

In this work, we examine the ultrafast carrier dynamics of n-type modulation doped GaAs/AlGaAs core-shell nanowires and assess the effects of doping on electron mobility and carrier lifetime. Measurement of room-temperature photoconductivity was carried out with subpicosecond resolution via optical pump terahertz-probe (OPTP) spectroscopy.<sup>28</sup> This technique is contact-free and allows the doping density of the nanowires to be extracted accurately at room temperature without artifacts associated with making electrical contacts.<sup>36</sup> To our knowledge, the OPTP technique has not yet been used to determine the carrier concentration in modulation doped nanowires. From OPTP measurements, we show that n-type modulation doping is indeed effective in the core-shell GaAs/AlGaAs nanowires with an n-type carrier concentration of  $10^{16}$  cm<sup>-3</sup> measured in the core. More significantly, we show that the high electron mobility is retained through modulation doping and determine a photoconductivity lifetime of over 3 ns and a photoluminescence lifetime of over 2 ns. Such a long carrier lifetime and maintained high electron mobility at room temperature suggest that modulation doped GaAs could make excellent candidates for optoelectronic devices and that OPTP spectroscopy offers a reliable technique for doping characterization.

Core—shell GaAs/Al<sub>0.33</sub>Ga<sub>0.67</sub>As nanowires were grown on a p-type (111)Si substrate via molecular beam epitaxy (MBE) under conditions that maximize the yield of vertical nanowires (details of the growth parameters are provided in the Supporting Information). The structure of the nanowire heterostructures used in this study is illustrated in Figure 1a, which shows a cross-section of a nanowire perpendicular to its long axis. Rods of GaAs



**Figure 1.** HAADF-STEM cross-section image of (a) a representative GaAs/Al<sub>0.33</sub>Ga<sub>0.67</sub>As core—shell nanowire with modulation doping. A schematic description of the core—shell structure has been superposed to the left of the STEM image. The arrows indicate the regions with different contrast that correspond to the doped layer crossing the Al-rich segments. (b) Nextnano<sup>37</sup> simulation of the electron density profile assuming a nominal doping density of  $4.5 \pm 0.5 \times 10^{18}$  cm<sup>-3</sup> for the modulation-doped nanowire. (c) Energy band diagram for modulation-doped nanowire with electron density profile (green line) super-imposed. The conduction (valence) band edge is shown in black (red) and the chemical potential or "Fermi level" is represented as the blue line. The red dashed line in (b) marks the path to which the band diagram corresponds.

with a diameter of ~50 nm were coated with 40 nm wide shells of larger bandgap  $Al_{0.33}Ga_{0.67}As$ . Si impurities were used to produce a dopant layer at a distance of 12 nm from the GaAs/Al\_{0.33}Ga\_{0.67}As interface with a nominal doping density of

 $4.5 \pm 0.5 \times 10^{18}$  cm<sup>-3</sup>. Finally, to limit oxidation of the nanowires in air, a thin (5 nm thick) GaAs capping layer was coated on top of the Al<sub>0.33</sub>Ga<sub>0.67</sub>As shells. Modulation n-type doping of the GaAs core region of the nanowire is then achieved as a result of donated electrons from the ionized Si donor atoms in the doped region of the large bandgap Al<sub>0.33</sub>Ga<sub>0.67</sub>As shell migrating to the lower potential energy of the GaAs core region. A self-consistent solution of the Schrödinger and Poisson equations for this structure,<sup>37</sup> as shown in Figure 1b,c, illustrates this process. For use as a reference sample, undoped core-shell GaAs/ Al<sub>0 33</sub>Ga<sub>0 67</sub>As nanowires were also grown via MBE under similar growth conditions. These undoped nanowires had the same geometry and morphology as the modulation doped nanowires but did not contain the doped layers of Si impurities. Both the modulation doped and undoped nanowires were transferred to z-cut quartz substrates for measurement. A comparison of these two samples then allowed the effects of modulation doping to be examined.

Figure 1a shows a high-angle annular dark-field scanning transmission electron microscopy (HAADF-STEM) crosssection image of a representative nanowire for the modulationdoped sample. A schematic illustration of the core-shell structure has been superimposed on the left side of the STEM image. In this contrast image, the brightness is proportional to the atomic number squared, so the darker regions highlight the presence of lighter elements. Thus, the modulation doping can be clearly identified where the doping layer crosses the Al-rich stripes, as marked by the arrows in Figure 1a. Structural characterization in the axial direction confirms that both samples have a similar crystalline structure, namely the zincblende crystalline phase with the presence of twin defects (shown in the high-resolution TEM images provided in the Supporting Information). Figure 1b shows results from the numerical simulation<sup>37</sup> of the electron density profile for this modulation doped structure. The electron density profile takes into account the doping expected for a 5 nm thick doping layer and has the same geometry as measured from the TEM images. Figure 1c depicts this electron density profile superposed onto a simulated energy band diagram for the modulation doped sample. It can clearly be seen that the dopant layer is situated in the Al<sub>0.33</sub>Ga<sub>0.67</sub>As shell and alters the conduction band profile.

The photoconductivity dynamics of the nanowires were measured at room temperature by the OPTP setup described in the Supporting Information. The nanowires were photoexcited with a near-infrared laser of wavelength 800 nm ( $E_{\text{photon}}$  = 1.55 eV) and pulse duration of 35 fs at fluences between 0.46 and 225  $\mu$ J cm<sup>-2</sup>. This wavelength is ideal as electron-hole pairs were only generated in the central core region and capping layer of the nanowire and not in the Al<sub>0.33</sub>Ga<sub>0.67</sub>As shell. The photoexcitation induces a change,  $\Delta E_{i}$  in the transmission of the electric field of terahertz probe pulse, *E*. The value of  $\Delta E/E$  is proportional to the photoinduced conductivity of the nanowires and thereby the change in free carrier concentration<sup>38</sup> (see Supporting Information). The photoinduced conductivity is assumed to arise solely from the photoexcited electrons, as the effective mass of holes is significantly greater than the effective mass of electrons in GaAs.

Figure 2a shows the decay of the free electron concentration with time after photoexcitation for the modulation-doped sample at fluences of 11.4, 45.5, and  $114 \,\mu\text{J}\,\text{cm}^{-2}$ . The photoconductivity clearly shows a rapid rise within the first 5 ps after photoexcitation followed by a slow decay. The recombination dynamics of



**Figure 2.** (a) Photoinduced change of free electron concentration in modulation doped GaAs nanowires as a function of time after photoexcitation by 35 fs pulses of 1.55 eV photons at fluences of 11.4, 45.5, and 114  $\mu$ J cm<sup>-2</sup>. I, II, III, and IV represent delays of 25, 100, 250, and 1000 ps, respectively. (b) Comparison of the decay of normalized photoconductivity (circles) and normalized photoluminescence (squares) for modulation doped and undoped nanowires. The excitation fluence for the photoconductivity and PL experiments were 114 and 0.2  $\mu$ J cm<sup>-2</sup>, respectively, and PL was detected at a wavelength of 860 nm (corresponding to emission from the GaAs core). All measurements were performed at room temperature.

photoinjected electrons in a semiconductor may be described by the differential equation,<sup>39</sup>

$$\frac{\mathrm{d}n(t)}{\mathrm{d}t} = -k_1 n - k_2 n^2 - k_3 n^3 \tag{1}$$

where n(t) is the electron density as a function of time, t, after photoexcitation.  $k_1$  is a decay constant describing the rate of monomolecular processes, such as trap-assisted recombination, recombination of photoinjected electrons with extrinsic holes or exciton recombination, the bimolecular recombination constant is given by  $k_2$  and  $k_3$  is the rate for Auger recombination.<sup>40</sup> In the OPTP experiments, the initial photoinjected electron density, n(t = 0), may be freely set by adjusting the fluence of the laser pulse that photoexcites the sample. Thus, by fitting eq 1 to photoconductivity decay curves measured for a range of excitation fluences and setting  $k_1$ ,  $k_2$ , and  $k_3$  as global parameters, it is possible to determine these decay constants with a high degree of accuracy. Performing this global fitting procedure to the data shown in Figure 2a revealed decay constants for bimolecular and Auger recombination that were negligible ( $k_2$ ,  $k_3 \simeq 0$ ), leaving only a monomolecular term,  $k_1 = 2.6 \pm 0.4 \times 10^8 \text{ s}^{-1}$ . Thus, the recombination is monoexponential with a photoinjected electron recombination lifetime of  $3.9 \pm 0.3$  ns. The global fits are shown by the solid black lines in Figure 2a. As excitonic behavior is not expected to dominate in this system at room temperature and the sample is n-type, the recombination mechanism for the modulation doped sample appears to be trap-assisted, as is typical for GaAs at room temperature.<sup>29</sup>

To better understand the mechanism of charge recombination, we also recorded the time-resolved photoluminescence (PL) dynamics of single nanowires at room temperature and compared the results to the photoconductivity decays measured using the OPTP technique. Single nanowires were excited with 100 fs laser pulses with a center wavelength of 800 nm and a fluence of  $0.2 \,\mu$ J/cm<sup>2</sup> and PL measured as a function of time after photoexcitation at a wavelength of 860 nm. The time-resolved micro-PL setup is described in the Supporting Information.

Figure 2b shows a comparison between the room-temperature photoconductivity and PL lifetimes for both the modulation doped nanowires and the undoped reference. With OPTP, the signal measures the change in electron density as a function of time after photoexcitation, whereas the PL setup measures the rate of electron—hole recombination. Thus, the PL intensity is proportional to the product of the electron and hole density distributions and for PL to be seen, the electron and hole wave functions must spatially overlap.<sup>41</sup> It is clear from Figure 2b that for each sample the PL dynamics and photoconductivity dynamics are remarkably similar. This is in stark contrast to similar measurements on highly polytypic InP nanowires for which the PL emission decayed significantly faster than the photoconductivity due to spatial separation of the photoexcited electrons and holes.<sup>41</sup>

The photoconductivity lifetime for the modulation doped nanowires  $(3.9 \pm 0.3 \text{ ns})$  is found to be significantly longer than for the undoped reference  $(1.5 \pm 0.4 \text{ ns})$ . Similarly, the PL lifetime of the modulation doped nanowire  $(2.39 \pm 0.05 \text{ ns})$  is significantly longer than that of the undoped reference  $(1.1 \pm 0.2 \text{ ns})$ . The increase in the conductivity lifetime we observe as a result of modulation doping suggests that modulation doping passivates electron traps in the nanowires. As modulation doping is expected to generate high electron densities at the GaAs/Al<sub>0.33</sub>Ga<sub>0.67</sub>As interfaces (see Figure 1b), it is thus likely that donated electrons passivate interfacial trap states located at the GaAs/Al<sub>0.33</sub>Ga<sub>0.67</sub>As boundary.

In order to gain further insight into charge-carrier scattering and recombination mechanisms, photoconductivity spectra for both the modulation doped and undoped sample were measured. Figure 3 shows the photoconductivity spectra at an excitation fluence of  $114 \,\mu$ J cm<sup>-2</sup> for both samples. Spectra were obtained at various delays of 25, 100, 250, and 1000 ps after photoexcitation. The conductivity spectra for both samples display a distinct Lorentzian response. The resonance clearly shifts to lower frequencies with time after photoexcitation, as can be seen from the arrows in Figure 3a-d,e-h. The reduction of resonant frequency with decreasing electron density is a key attribute of localized surface plasmon (LSP) modes.<sup>42</sup> LSP modes have been well documented for metallic nanostructures, where the resonant frequency lies within the ultraviolet, visible, and near-infrared ranges.<sup>43,44</sup> For semiconductor nanostructures, which have a lower charge-carrier density than metallic nanostructures, the resonant frequency lies within the terahertz range.<sup>29,45,46</sup> We have previously shown that GaAs nanowires exhibit LSP modes within the terahertz range.<sup>29,46,47</sup>



**Figure 3.** Time-resolved conductivity of photoexcited electrons for the n-type, modulation doped sample at times (a) 25, (b) 100, (c) 250, and (d) 1000 ps after photoexcitation and for the undoped sample at times (e) 25, (f) 100, (g) 250, and (h) 1000 ps after photoexcitation. Panels a–d correspond to times I, II, III, and IV shown in Figure 2. The incident pump pulse excitation fluence was 114  $\mu$ J cm<sup>-2</sup> for both samples. The symbols represent the measured data and the solid lines the fitted plasmon responses. The real (blue) and imaginary (red) components of the conductivity are plotted with arrows indicating the resonant surface plasmon frequency,  $\omega_{0}$ , for each spectrum. All measurements were performed at room temperature.

The complex photoconductivity of a free electron plasma with a surface plasmon resonance is given by

$$\Delta \sigma = \frac{ine^2 \omega}{m_{\rm e}^* (\omega^2 - \omega_0^2 + i\omega\gamma)} \tag{2}$$

where *n* is the electron density, *e* is the electronic charge,  $m_e^*$  is the effective electron mass, and  $\gamma$  is the momentum scattering rate.  $\omega_0$  is the surface plasmon resonant frequency given by

$$\omega_0(n) = \sqrt{\frac{fne^2}{m_e^* \varepsilon_r \varepsilon_0}}$$
(3)

where  $\varepsilon_r$  is the dielectric constant of GaAs nanowires at terahertz frequencies,  $\varepsilon_0$  is the permittivity of free space, and *f* is a constant that depends on the nanowire geometry and surrounding dielectric medium.<sup>47</sup> For doped samples, there is a significant charge-carrier density present without photoexcitation and the complex photoconductivity expression must therefore be modified.<sup>41</sup> When both intrinsic and extrinsic electrons are considered with an equilibrium electron density before photoexcitation of  $n_{dr}$  the complex photoconductivity then becomes

$$\Delta\sigma = \frac{ie^2\omega}{m_e^*} \left[ \frac{n_{\text{total}}}{\omega^2 - \{\omega_0(n_{\text{total}})\}^2 + i\omega\gamma} - \frac{n_d}{\omega^2 - \{\omega_0(n_d)\}^2 + i\omega\gamma} \right]$$
(4)

where  $n_{\text{total}} = n_{\text{photo}} + n_{\text{d}}$  is the sum of the photoexcited and donated electon density.

The solid lines in Figure 3 show that eq 4 provides an excellent fit to the measured photoconductivity spectra of both doped and undoped nanowire samples. For each sample, a global fitting routine was applied to all spectra at various times after photoexcitation for which *f* was fixed at  $0.25^{41}$  and  $n_d$  was set as a global parameter, common to all spectra for the given sample.  $n_{\text{photo}}$  and  $\gamma$  were set to local fitting parameters for each spectrum, as the electron density and scattering rate vary with time after photoexcitation. For  $m_e^*$  and  $\varepsilon_r$ , the bulk values for GaAs of  $0.063m_e^*$  and 12.95 were used, respectively. From these fits, the doping level was then extracted. For the modulation doped sample, the donor density was found to be  $1.10 \pm 0.06 \times 10^{16}$ cm<sup>-3</sup>, while for the undoped sample it was found to be negligible within our measurement and fitting accuracy.

To confirm the validity of the model, photoconductivity spectra were also measured as a function of excitation fluence for both the modulation doped nanowires and the undoped reference. Spectra were recorded 100 ps after photoexcitation by 1.55 eV ( $\lambda$  = 800 nm) photons of eight different excitation fluences between 6.46  $\mu$ J cm<sup>-2</sup> and 225  $\mu$ J cm<sup>-2</sup> (the spectra are shown in Figure S6 of the Supporting Information). The results of globally fitting these spectra with eq 4 are summarized in Figure 4a, which shows the extracted plasmon frequency,  $\omega_0(n_{\text{total}})$ , plotted against the square-root of the photoinjected electron density,  $(n_{\text{photo}})^{1/2}$ . For the undoped sample (blue line), as expected a linear relationship is seen  $\omega_{o} \propto (n_{photo})^{1/2}$ , however for the doped sample (red line) a deviation from the linear relationship occurs. This deviation comes from the nonzero electron concentration,  $n_{d}$ , prior to photoexcitation. The value for the donated electron concentration from the global fit of the fluence dependent data was  $n_d = 1.07 \pm 0.12 \times 10^{16} \text{ cm}^{-3}$ , which showed excellent agreement with the independently measured value of  $1.10 \pm 0.06 \times 10^{16}$  cm<sup>-3</sup> determined from photoconductivity spectra measured as a function of time after photoexcitation.

The mobility of electrons from both the modulation doped and undoped nanowire samples are shown in Figure 4b as a function of the total electron density,  $n_{\text{total}}$ . The mobility,  $\mu$ , was calculated according to  $\mu = e/m_e^*\gamma$ , using the scattering rates,  $\gamma$ , extracted from the previously described global fits to the photoconductivity spectra displayed in Figure 3. As can be seen from Figure 4b, the mobility was electron density dependent and ranged from 1680  $\pm$  100 to 2200  $\pm$  300 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> for the modulation doped sample and between 2300  $\pm$  120 and 2960  $\pm$ 290 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> for the undoped sample.

Importantly, no significant degradation of mobility is observed for the modulation-doped sample compared with the undoped reference sample for similar values of electron density. In previous doping studies, impurity scattering has been found to reduce the electron mobility in doped GaAs nanowires,<sup>15</sup> while from our results it is clear that modulation doping does not degrade mobility. Figure 4b shows that at a total electron density value of approximately  $3.5 \times 10^{16}$  cm<sup>-3</sup>, the electron mobility for both samples is similarly high at approximately 2200 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>,



**Figure 4.** (a) Plasmon frequency,  $\omega_0(n_{\text{total}})$ , plotted against the squareroot of the photoexcited electron density,  $(n_{\text{photo}})^{1/2}$ , for the modulation doped (red squares) and undoped (blue squares) nanowire samples. Each data point corresponds to a fit of  $\omega_0(n_{\text{total}})$  (via eq 4) to a conductivity spectrum of nanowires photoexcited at a set fluence. These 16 fluence-dependent conductivity spectra are shown in Figure S6 of the Supporting Information. The solid red line shows eq 3 with f = 0.25,  $n = n_{\text{total}}$  and doping density of  $n_d = 1.07 \pm 0.12 \times 10^{16} \text{ cm}^{-3}$  for the modulation-doped sample. The corresponding curve with  $n_d = 0$  is shown in blue. (b) Room-temperature electron mobility extracted for the modulation doped (red squares) and undoped sample (blue squares) plotted against the total electron density  $n_{\text{total}}$ . These data were extracted from the fits displayed in Figure 3. The dashed line represents a fit to eq 5, which is an empirical, low-field model of electron mobility.

regardless of carriers being injected through doping or photoexcitation. Furthermore, the electron mobility for both samples decrease with increasing electron density, due to an increase in carrier-carrier scattering.

An empirical, low-field mobility model for III–V compounds was used to fit the mobility data. The model has been described previously<sup>48</sup> and is presented in the Supporting Information. It states that the extracted mobilities when plotted against  $n_{\text{total}}$  should take the following form

$$\mu = \mu_{\min} + \frac{\mu_{\max} - \mu_{\min}}{1 + \left(\frac{n_{\text{ref}}}{n}\right)^{\lambda}}$$
(5)

where  $\mu_{\min}$  is the minimum electron mobility and  $\mu_{\max}$  the maximum electron mobility for the system,  $n_{\text{ref}}$  is the electron concentration at which the mobility reduces to half its maximum value at low doping, and  $\lambda$  is a scaling factor related to the material. At high doping concentrations, the mobility saturates at  $\mu_{\min}$ , which is temperature-independent; at very low doping concentrations, the mobility saturates at  $\mu_{\max}$ , which is the lattice-limited mobility and reduces with increasing temperature. By fitting this equation to all the extracted mobility points with fitted values of  $\lambda = 1.63$  and  $n_{\text{ref}} = 6.34 \pm 0.25 \times 10^{17} \text{ cm}^{-3}$ , a minimum electron mobility of  $680 \pm 120 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$  and a maximum

electron mobility of  $3290 \pm 20$  cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> were obtained. As the model, which only takes into account carrier-carrier scattering, fits the measured mobilities for both the modulation doped and undoped samples, it can be deduced that modulation doping avoids the reduction in electron mobility associated with bulk doping. As the total electron concentration increases with n-type modulation doping, a reduction in mobility occurs as a result of carrier-carrier scattering. However, when the increased electron density of the modulation doped sample is considered only a small reduction in electron mobility is observed, as can be seen in Figure 4 where the extracted mobilities coincide with the empirical model. This minimal reduction in electron mobility is due to the dopants being situated away from the interface, reducing scattering of charge-carriers in the core of the nanowire with ionised dopants. Thus, modulation doped GaAs nanowires provide a high electron mobility of 2200  $\pm$  $300 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$  suggesting that n-type modulation doping could be highly attractive for nanowire applications in future optoelectronic devices.

However, there is still much to be done to further improve the electron mobility in semiconductor nanowires. Even considering the effect of carrier-carrier scattering, the upper electron mobility values  $\mu_{max}$  for both the modulation doped and undoped reference nanowire samples are significantly lower than those for bulk GaAs.<sup>49</sup> Electron scattering at the nanowire surfaces is likely to be a significant contributing factor for nanowires owing to the large surface area-to-volume ratio of nanowires. Thus, optimized surface passivation<sup>50</sup> is an important route to increasing the electron mobility in nanowires. Furthermore, polytypism, which was significant in our samples (see Figures S1 and S2 of the Supporting Information), is also likely to be a contributing factor to this reduction in mobility from bulk values and could be minimized with pure-phase structures, as we have shown previously.<sup>30</sup> In addition it was recently shown that electron mobility can also be enhanced by increasing the nanowire shell thickness.<sup>51</sup>

In conclusion, we have presented the first noncontact terahertz frequency measurements of the electronic properties of modulation doped GaAs nanowires. Terahertz spectroscopy, in particular the OPTP spectroscopy technique, provides an ideal tool for accurately measuring the photoconductivity lifetime, electron mobility, and also the doping levels in nanowires. We have demonstrated that core-shell GaAs nanowires can be successfully grown with an extrinsic electron concentration of  $1.10 \pm 0.06 \times 10^{16}$  cm<sup>-3</sup>. The photoconductivity and photoluminescence lifetimes were found to be  $3.92 \pm 0.27$  and  $2.39 \pm 0.05$  ns at room tempertaure. These lifetimes are considerably longer than has been seen for GaAs or other III-V nanowires previously, highlighting the potential of these modulation-doped nanostructures for future optoelectronic and photovoltaic devices. A value for the room-temperature electron mobility was also extracted from the photoconductivity spectra and found to be  $2200 \pm 300 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ . This value is high for GaAs nanowires and shows that there is no significant degradation of the electron mobility when compared to an undoped reference. Therefore, modulation doping appears to be an excellent way of controlling conductivity in semiconductor nanowires while retaining a high electron mobility, and OPTP spectroscopy offers a rapid noncontact method of characterizing and hence further improving the electrical properties of these heterostructures.

### ASSOCIATED CONTENT

#### **Supporting Information**

Description of experiments (nanowire growth, sample preparation, electron microscopy, terahertz time-domain spectroscopy, time-resolved microphotoluminescence); TEM images of doped and undoped sample; Schrödinger-Poisson simulation results for photoexcited nanowires; photoconductivity dynamics data for undoped nanowires as a function photoexcitation-fluence; photoconductivity spectra as a function of photoexcitationfluence for both doped and undoped nanowires; details of data analysis (calculations for converting terahertz transmission data to photoconductivity, descriptions of rate equations used for modeling of time-resolved conductivity data, description of empirical model used for fitting mobilities from photoconductivity spectra) can all be found in the Supporting Information. This material is available free of charge via the Internet at http://pubs.acs.org/.

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#### Notes

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